Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	14227	(lattice sparse or scattered) near5 (exposure or pattern or writing)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR *	ON	2006/10/30 15:24
L2	676997	(slm or spatial near2 light near2 modulat\$3 or individually near3 controllable near2 elements or mems or dmd or digital near2 (mirror or micromirror) near2 device or micromirror or micro near2 mirror or light near2 valve or lcd or liquid near2 crystal)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:39
L3	2727	1 and 2	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 14:26
L4	23777	(irradiation or radiation or exposure) near5 group	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:09
L5	90	3 and 4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 14:28
L6	9	2 same (main or primary or first) near2 scan\$4 same 4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 14:29
L7	15038	(lattice sparse or scattered) near5 (exposure or pattern or writing or drawing)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 14:44
L8	92	2 and 4 and 7	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:05

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L9	2177	1 and (355/53,67-71,77.ccls. or "250"/\$.ccls. or "347"/\$.ccls. or 378/34,35.ccls. or "430"/\$.ccls.)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:07	
L10	2224	7 and (355/53,67-71,77.ccls. or "250"/\$.ccls. or "347"/\$.ccls. or 378/34,35.ccls. or "430"/\$.ccls.)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:07	
L11	545	2 and 10	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:08	
L12	508	11 not (5 or 8)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:08	
L13	53987	(irradiation or radiation or exposure or pattern\$3) near5 group	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:38	
L14	173	(7 same 13)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:10	
L15	2	12 and 14	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:11	
L16	32	2 and 14	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:11	
L18	14457	(lattice or sparse\$2 or scattered) near5 (exposure or pattern or writing)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:26	

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L19	33	2 and (18 same 13)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:27
L20	1	19 not 16	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:25
L21	35946	(lattice or sparse\$2 or scattered) same (exposure or pattern or writing)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:38
L22	78	2 and (21 same 13)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:27
L23	45	22 not (19)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:27
L24	8	("4083035" "4516262" "5450218" "6414763").PN. OR ("6549664").URPN.	US-PGPUB; USPAT; USOCR	OR .	ON	2006/10/30 15:34
L25	2372	(lattice or sparse\$2 or scattered) same (exposure or pattern or writing).clm.	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:38
L26	12514	(irradiation or radiation or exposure or pattern\$3) near5 group.clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR ·	ON	2006/10/30 15:38

L27	62918	(slm or spatial near2 light near2 modulat\$3 or individually near3 controllable near2 elements or mems or dmd or digital near2 (mirror or micromirror) near2 device or micromirror or micro near2 mirror or light near2 valve or lcd or liquid near2 crystal).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:40
L28	6	27 and (25 same 26)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/30 15:40

10/30/06 3:41:26 PM Page 4 C:\Documents and Settings\DRutledge\My Documents\EAST\workspaces\10814429 pattern writing apparatus and method.wsp